

SLOVENSKI STANDARD SIST EN ISO 19749:2023

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Nanotehnologije - Meritve porazdelitve velikosti in oblike delcev s skenirno elektronsko mikroskopijo (ISO 19749:2021)

Nanotechnologies - Measurements of particle size and shape distributions by scanning electron microscopy (ISO 19749:2021)

Nanotechnologien - Messung der Partikelgrößenverteilung und Partikelformverteilung mit Rasterelektronenmikroskopie (ISO 19749:2021)

Nanotechnologies - Détermination de la distribution de taille et de forme des particules par microscopie électronique à balayage (ISO 19749:2021)

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EUROPEAN STANDARD NORME EUROPÉENNE EUROPÄISCHE NORM **EN ISO 19749**

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English Version

Nanotechnologies - Measurements of particle size and shape distributions by scanning electron microscopy (ISO 19749:2021)

Nanotechnologies - Détermination de la distribution de taille et de forme des particules par microscopie électronique à balayage (ISO 19749:2021)

Nanotechnologien - Messung der Partikelgrößenverteilung und Partikelformverteilung mit Rasterelektronenmikroskopie (ISO 19749:2021)

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Contents	Pag	e
Euronean foreword		3

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SIST EN ISO 19749:2023
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European foreword

The text of ISO 19749:2021 has been prepared by Technical Committee ISO/TC 229 "Nanotechnologies" of the International Organization for Standardization (ISO) and has been taken over as EN ISO 19749:2023 by Technical Committee CEN/TC 352 "Nanotechnologies" the secretariat of which is held by AFNOR.

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Nanotechnologies — Measurements of particle size and shape distributions by scanning electron microscopy

Nanotechnologies — Détermination de la distribution de taille et de forme des particules par microscopie électronique à balayage

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Contents		Page	
Fore	word		v
Intro	oductio	n	vi
1	Scop	e	1
2	-	native references	
3		ns and definitions	
3	3.1	General terms	
	3.2	Core terms: image analysis	
	3.3	Core terms: statistical symbols and definitions	
	3.4	Core terms: measurands and descriptors	
	3.5	Core terms: metrology	
	3.6	Core terms: scanning electron microscopy	
4		eral principles	
	4.1 4.2	SEM imagingSEM image-based particle size measurements	
	4.2	SEM image-based particle size measurements	
_			
5	Sam ₃	ple preparation Sample preparation fundamental information	
	5.1	General recommendations	
	5.3	Ensuring good sampling of powder or dispersion-in-liquid raw materials	
	0.0	5.3.1 Powders	14
		5.3.2 Nanoparticle dispersions in liquids	
	5.4	Ensuring representative dispersion	
	5.5	Nanoparticle deposition on a substrate	
		5.5.1 General S.5.2 Nanoparticle deposition on wafers and chips of silicon or other materials S.5.2	
		5.5.3 Nanoparticle deposition on TEM grids	17
	5.6	Number of samples to be prepared.	18
	5.7	Number of particles to be measured for particle size determination	18
	5.8	Number of particles to be measured for particle shape determination	19
6	Qual	ification of the SEM for nanoparticle measurements	19
7	Imag	ge acquisition	19
	7.1	General	
	7.2	Setting suitable image magnification and pixel resolution	23
8	Part	icle analysis	24
	8.1	Particle analysis fundamental information	24
	8.2	Individual particle analysis	
	8.3	Automated particle analysis	
	8.4	Automated particle analysis procedure example	
9		analysis	
	9.1 9.2	General	
	9.2	Raw data screening: detecting touching particles, artefacts and contaminants Fitting models to data	27 27
	9.4	Assessment of measurement uncertainty	27
		9.4.1 General	
		9.4.2 Example: Measurement uncertainty for particle size measurements	
		9.4.3 Bivariate analysis	29
10	Repo	orting the results	29
Ann	ex A (no	ormative) Qualification of the SEM for nanoparticle measurements	31
Anno	ex B (in	formative) Cross-sectional titanium dioxide samples preparation	36

Annex C (informative) Case study on well-dispersed 60 nm size silicon dioxide nanoparticles	38
Annex D (informative) Case study on 40 nm size titanium dioxide nanoparticles	46
Annex E (informative) Example for extracting particle size results of SEM-based nanoparticle measurements using ImageJ	55
Annex F (informative) Effects of some image acquisition parameters and thresholding methods on SEM particle size measurements	57
Annex G (informative) Example for reporting results of SEM-based nanoparticle measurements	s 61
Rihliogranhy	71

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https://standards.iteh.ai/catalog/standards/sist/d6d2fff5-0219-486b-b9ca-1be9cfdb68ab/sist en-iso-19749-2023

Foreword

ISO (the International Organization for Standardization) is a worldwide federation of national standards bodies (ISO member bodies). The work of preparing International Standards is normally carried out through ISO technical committees. Each member body interested in a subject for which a technical committee has been established has the right to be represented on that committee. International organizations, governmental and non-governmental, in liaison with ISO, also take part in the work. ISO collaborates closely with the International Electrotechnical Commission (IEC) on all matters of electrotechnical standardization.

The procedures used to develop this document and those intended for its further maintenance are described in the ISO/IEC Directives, Part 1. In particular, the different approval criteria needed for the different types of ISO documents should be noted. This document was drafted in accordance with the editorial rules of the ISO/IEC Directives, Part 2 (see www.iso.org/directives).

Attention is drawn to the possibility that some of the elements of this document may be the subject of patent rights. ISO shall not be held responsible for identifying any or all such patent rights. Details of any patent rights identified during the development of the document will be in the Introduction and/or on the ISO list of patent declarations received (see www.iso.org/patents).

Any trade name used in this document is information given for the convenience of users and does not constitute an endorsement.

For an explanation of the voluntary nature of standards, the meaning of ISO specific terms and expressions related to conformity assessment, as well as information about ISO's adherence to the World Trade Organization (WTO) principles in the Technical Barriers to Trade (TBT), see www.iso.org/iso/foreword.html.

This document was prepared by Technical Committee ISO/ TC 229, Nanotechnologies.

Any feedback or questions on this document should be directed to the user's national standards body. A complete listing of these bodies can be found at www.iso.org/members.html.

en-iso-19749-2023

Introduction

This document provides guidance for measuring and reporting the size and shape distributions of nanometer-scale particles using images acquired by the scanning electron microscope (SEM). This document applies to the SEM-based measurement of larger particles also. Nanoparticles are threedimensional (3D) objects, but the SEM image is only a two-dimensional (2D) representation of the 3D shape from a certain viewing angle. The SEM image carries valuable information about the size and shape of particles. While the SEM image does contain a certain amount of 3D information, for sake of simplicity, this document does not deal with reconstructing 3D information. Rigorous three-dimensional characterization of nanoparticles would include size, shape, surface structure (e.g. texture), surface and internal material composition, and their locations in the investigated 3D volume. This document deals with two attributes of morphology, size and shape, for discrete and aggregated nano-objects (materials with at least one dimension in the nanometer-scale, i.e. within 1 nm to 100 nm). Suitable sample preparation is essential to obtaining high-quality electron microscope images and preferred techniques often vary with the sample material. It is equally important to make sure that the SEM itself is suitable to carry out the measurements with the required uncertainty. Typical guidance suggests that a large number, several hundreds or thousands of particles need to be measured for statistically sound size and shape distribution results. The actual number of nano-objects needed to be measured depends on the sample, the required uncertainty and on the performance of the SEM. Statistical evaluation of the data and the evaluation of uncertainty of the measurands are included as part of the measurement and reporting procedures.

This document contains measurement procedures, particle and data analysis and reporting clauses. In the Annexes, there are specific examples for measurements and guidance for the qualification of the SEM for reliable quantitative measurements. Automation of the image acquisition and data analysis can reduce cost and improve the quality of the results. Measurements of samples of discrete nanoparticles are generally easier to carry out with automated image acquisition and particle analysis systems. Measurements of complex discrete nanoparticles, and aggregates or agglomerates of nanoparticles may require operator-assisted image acquisition and analysis. Evaluation of particle shape is facilitated by many pertinent analysis software solutions that allow for automatic selection of various shape attributes as well.

en-iso-19749-2023

Nanotechnologies — Measurements of particle size and shape distributions by scanning electron microscopy

1 Scope

This document specifies methods of determining nanoparticle size and shape distributions by acquiring and evaluating scanning electron microscope images and by obtaining and reporting accurate results.

NOTE 1 This document applies to particles with a lower size limit that depends on the required uncertainty and on the suitable performance of the SEM, which is to be proven first -according to the requirements described in this document.

NOTE 2 This document applies also to SEM-based size and shape measurements of larger than nanoscale particles.

2 Normative references

The following documents are referred to in the text in such a way that some or all of their content constitutes requirements of this document. For dated references, only the edition cited applies. For undated references, the latest edition of the referenced document (including any amendments) applies.

ISO/IEC Guide 99, International vocabulary of metrology — Basic and general concepts and associated terms (VIM)

ISO 9276-1, Representation of results of particle size analysis — Part 1: Graphical representation

ISO 9276-2, Representation of results of particle size analysis — Part 2: Calculation of average particle sizes/diameters and moments from particle size distributions

ISO 9276-3, Representation of results of particle size analysis — Part 3: Adjustment of an experimental curve to a reference model

ISO 9276-5, Representation of results of particle size analysis — Part 5: Methods of calculation relating to particle size analyses using logarithmic normal probability distribution

ISO 9276-6, Representation of results of particle size analysis — Part 6: Descriptive and quantitative representation of particle shape and morphology

ISO 13322-1, Particle size analysis — Image analysis methods — Part 1: Static image analysis methods

ISO 16700, Microbeam analysis — Scanning electron microscopy — Guidelines for calibrating image magnification

ISO/IEC 17025, General requirements for the competence of testing and calibration laboratories

ISO/TS 24597:2011, Microbeam analysis — Scanning electron microscopy — Methods of evaluating image sharpness

ISO 26824, Particle characterization of particulate systems — Vocabulary

ISO/TS 80004-1, Nanotechnologies — Vocabulary — Part 1: Core terms

ISO/TS 80004-2, Nanotechnologies — Vocabulary — Part 2: Nano-objects

ISO/TS 80004-3, Nanotechnologies — Vocabulary — Part 3: Carbon nano-objects

ISO/TS 80004-4, Nanotechnologies — Vocabulary — Part 4: Nanostructured materials

ISO/TS 80004-6, Nanotechnologies — Vocabulary — Part 6: Nano-object characterization

3 Terms and definitions

For the purposes of this document, the terms and definitions given in ISO/IEC Guide 99, ISO 9276-6, ISO 26824, ISO/TS 80004-1, ISO/TS 80004-2, ISO/TS 80004-3, ISO/TS 80004-4, ISO/TS 80004-6, and the following apply.

ISO and IEC maintain terminological databases for use in standardization at the following addresses:

- ISO Online browsing platform: available at https://www.iso.org/obp
- IEC Electropedia: available at http://www.electropedia.org/

3.1 General terms

3.1.1

nanoscale

length range from approximately 1 nm to 100 nm

Note 1 to entry: Properties that are not extrapolations from larger sizes are predominantly exhibited in this length range.

[SOURCE: ISO/TS 80004-1:2015, 2.1]

3.1.2

nano-object

discrete piece of material with one, two or three external dimensions in the *nanoscale* (3.1.1)

[SOURCE: ISO/TS 80004-1:2015, 2.5, modified — Note 1 to entry and the source have been deleted.]

3.1.3

particle

minute piece of matter with defined physical boundaries

[SOURCE: ISO/TR 16197:2014, 3.10, modified — Notes 1, 2 and 3 to entry and the source have been deleted.]

3.1.4

primary particle

original source particle (3.1.3) of agglomerates (3.1.5) or aggregates (3.1.6) or mixtures of the two

[SOURCE: ISO 26824:2013, 1.4, modified — Notes 1, 2 and 3 to entry have been deleted.]

3.1.5

agglomerate

collection of weakly or medium strongly bound *particles* (3.1.3) where the resulting external surface area is similar to the sum of the surface areas of the individual components

Note 1 to entry: Agglomerate originates from the Latin "agglomerare" meaning "to form into a ball".

Note 2 to entry: The forces holding an agglomerate together are weak forces, for example van der Waals forces or simple physical entanglement.

Note 3 to entry: Agglomerates are also termed secondary particles and the original source particles are termed *primary particles* (3.1.4).

[SOURCE: ISO 26824:2013, 1.2, modified — Note 1 to entry has been added.]

3.1.6

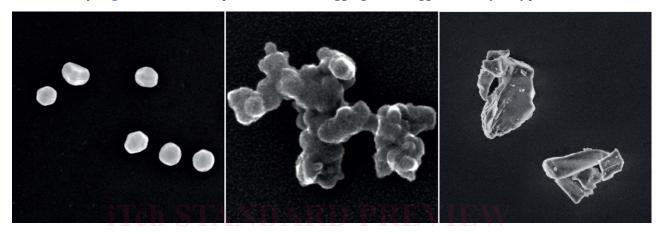
aggregate

particle (3.1.3) comprising strongly bonded or fused particles where the resulting external surface area is significantly smaller than the sum of surface areas of the individual components

Note 1 to entry: The forces holding an aggregate together are strong forces, for example covalent bonds, or those resulting from sintering or complex physical entanglement, or otherwise combined former *primary particles* (3.1.4).

Note 2 to entry: Aggregate comes from the Latin "aggregat" meaning "herded together".

Note 3 to entry: Figure 1 shows examples of individual, aggregate and agglomerate (3.1.5) particles.



NOTE The images are projected views from certain angles of the 3D objects. Depending on the viewing angle, the observable size of particles can vary substantially.

Figure 1 — SEM images of individual gold (left) and carbon black aggregate (middle) and corundum agglomerate (right) particles

en-iso-19749-2023

[SOURCE: ISO 26824:2013, 1.3, modified — Notes 2 and 3 to entry have been added.]

3.1.7

nanoparticle

nano-object (3.1.2) with all external dimensions in the *nanoscale* (3.1.1) where the lengths of the longest and shortest axes of the nano-object do not differ significantly

[SOURCE: ISO/TS 80004-2:2015, 4.4, modified — Note 1 to entry has been deleted.]

3.1.8

particle size

X

dimension of a *particle* (3.1.3) determined by a specified measurement method and under specified measurement conditions

Note 1 to entry: Different methods of analysis are based on the measurement of different physical properties. Independent of the particle property actually measured, the particle size can be reported as a linear dimension, an area, or a volume.

Note 2 to entry: The symbol x is used denote linear particle (3.1.3) size. However, it is recognized that the symbol d is also widely used. Therefore, the symbol x may be replaced by d.

3.1.9

particle size distribution

distribution of the quantity of particles (3.1.3) as a function of particle size (3.1.8)

[SOURCE: ISO/TS 80004-6:2021, 4.1.2, modified — Notes 1 and 2 to entry have been deleted.]